IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application for:

Kazunari Honma et al.

Application No.: 10/631,858

Patent No.: 7,247,900

For: DIELECTRIC DEVICE HAVING DIELECTRIC FILM TERMINATED

BY HALOGEN ATOMS

Examiner: Howard Weiss

Art Unit: 2814

Filing Date: August 1, 2003

Confirmation No.: 9152

Customer No.: 60172

Mail Stop Certificate of Corrections Branch Commissioner for Patents

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Commissioner:

REQUEST FOR CERTIFICATE OF CORRECTION UNDER 37 CFR 1.323

Upon review of the above-referenced Letters Patent, an error was noted that was the mistake of the U.S. Patent and Trademark Office.

Please correct the following:

At the Title Page, item 56, under "References Cited" section,

-- OTHER PUBLICATIONS

Item I "Low Temperature Deposition Material", Section 4 "New Deposition Material", Ferroelectric Memory Advanced Process, September 13, 1999-should be added.

This non-patent literature (NPL) document was considered in the form PTO-1449 initialed by the Examiner on April 23, 2007, but this NPL document was incorrectly omitted in the front page of the issued patent.

Since the error is by the U.S. Patent Office, it is believed that no fee is required for these corrections. It is respectfully requested that a Certificate of Correction be issued.

The Commissioner is hereby authorized to charge shortages or credit overpayments to Deposit Account No. 500393.

Respectfully submitted, SCHWABE, WILLIAMSON & WYATT, P.C.

Dated: January 19, 2010

/Dennis M. de Guzman/ Dennis M. de Guzman Reg. No. 41,702

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PTO/SB/44 (09-07)

Approved for use through 08/31/2010. OMB 0651-0033
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(Also Form PTO-1690)

UNITED STATES PATENT AND TRADEMARK OFFICE CERTIFICATE OF CORRECTION

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PATENT NO. : 7,247,900

APPLICATION NO: 10/631,858

ISSUE DATE : 07-24-2007

INVENTOR(s) : Honma et al.

It is certified that an error appears or errors appear in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

Title Page, item 56, under "References Cited" section, -item I "Low Temperature Deposition Material" Section 4 "New Deposition Material" Ferroelectric Memory Advanced Process September 13, 1999- should be added

MAILING ADDRESS OF SENDER (Please do not use customer number below):

Schwabe, Williamson & Wyatt, P.C. 1420 Fifth Avenue, Suite 3010

Seattle, WA 98101

This collection of information is required by 37 CFR 1.322, 1.323, and 1.324. The information is required to obtain or retain a benefit by the public which is to file (and by the USFTO to process) an application. Confidentially is governed by 3 U.S.C. 122 and 37 CFR 1.14. This collection is either to itse 1.0 hour to complete, including gathering, preparing, and submitting the completed application from to the USFTO. Time will wary depending upon the Field/dual cases. Any control of the production of the produc